



November 6, 2008

To whom it may concern:

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S K - E l e c t r o n i c s C o . , L t d .
Y o s h i t a d a N o g a m i , P r e s i d e n t
(Stock Code: 6677)

C o n t a c t : Hideaki Horiuchi, Director

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Completion of the Industry's First Next-Generation Liquid Crystal Glass Substrate Photomask Plant

With the recent completion of construction for the next-generation liquid crystal glass substrate photomask plant ("Shiga Plant") in Koka City, Shiga Prefecture, the Company performed a construction completion ceremony on November 5, 2008. (Reference: "Acquisition of Fixed Assets" announced August 6 of last year)

1. Objective of the Shiga Plant Construction

The Company's existing Kyoto Plant (renamed from the Kumiya Plant in October 2008) is engaged in the manufacture of large-format photomasks for 8th generation liquid crystal glass substrates and older. The Kyoto Plant did not have enough space for the installation of production equipment to manufacture next-generation liquid crystal glass substrate photomasks for which demand is expected to grow significantly in the future.

Accordingly, the Company moved ahead of its competitors in constructing the "Shiga Plant" as a manufacturing facility for large-format photomasks for next-generation liquid crystal glass substrates as a means to be the first to respond to customer needs.

With the completion of the Shiga Plant construction and the early transition to manufacturing operations, the Company will begin deliveries to the "Manufacturing Complex for the 21st Century" facility under construction by Sharp Corporation in Sakai City, Osaka, as well as be in a position to respond to the needs of overseas customers, aiming to cement our claim as the leading company in the industry. We thank you, and ask for your continued support.

2. Commencement of Operations

Late December 2008

3. Shiga Plant Overview

□ Location: 38 Hinokigaoka, Minakuchi-cho, Koka City, Shiga Prefecture 528-0068

TEL: +81-748-65-1390 (reception) FAX: +81-748-65-1391

□ Site Area: 42,907 m²

□ Total Floor Area: 8,600 m²

4. Shiga Plant Concept

1) The Only 10th and 11th Generation Plant in the Industry

The Shiga Plant will be the first and only plant in the industry capable of manufacturing 10th and 11th generation ultra-large-format photomasks.

2) Maximum Level Clean Environment

All of the ceilings inside the facility are equipped with filters to increase clean levels. In addition, all floors use a steel grid grating to maintain the cleanest environment in the industry.

The plant uses a fully automated transport system to ensure airtight integrity and safety during transportation.

3) Concern for the Global Environment

All movement within the plant is electric, eliminating the use of fossil fuel energy such as gas and kerosene. Further, all packaging materials and cases are reused, further demonstrating the Company's commitment to environmentally sound practices.

4) Improved Efficiency

Ancillary facilities have been consolidated and the manufacturing equipment layout has been improved to create better efficiencies.

5) High Quality High Precision and Quick Delivery

The adoption of state-of-the-art equipment and processing technologies has resulted in higher quality higher precision and quicker delivery times.

6) Ease of Access

Situated in a location easily accessed by expressways and airports, the new plant will facilitate the smooth transportation of manufactured products to customer facilities. This ideal location will shorten delivery times.



(Shiga Plant)